

For structures Si_3N_4 (Silicon Nitride)

We can synthesize raw materials inexpensively using byproducts of polycrystalline silicon, introduce Si_3N_4 manufacturing technology of Japan using cheap labor and cheap energy, high quality and low price Si_3N_4 products can be provided became.

Characteristic

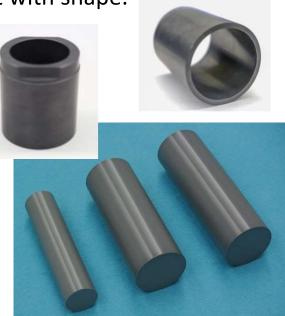
- Gas pressure sintering: Provide inexpensive and dense Si₃N₄ sintered body products using raw materials, gas, electricity etc. manufactured at our company.
- Maximum diameter φ 510 mm, maximum length 1200 mm, maximum thickness: Consult with shape.

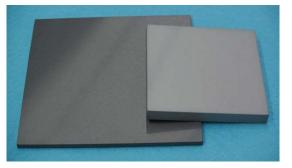




Physical properties

	Туре	JS-110	JS-120
Color		Black	Glay
Density	g/cm ³	3.24	3.24
Water absorption	%	0	0
Bending strength	MPa	700	700
Coefficient of elasticity	Gpa	300	300
Poisson's ratio		0.27	0.27
Thermal Conductivity	W/m·K(RT)	25	25
Electrical resistance	Ω • cm(RT)	>10 ¹⁴	>10 ¹⁴





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